

THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Chambers /

Serial No.:

10/649,425;

Filing Date:

08/27/2003

Customer No.: 23494

Art Unit:

2829

Examiner:

Sarkar, A.

Docket No.:

TI-35714

Conf. No.:

5169

Title: STRUCTURE AND METHOD TO FABRICATE SELF-ALIGNED TRANSISTORS

WITH DUAL WORK FUNCTION METAL GATE ELECTRODES

ELECTION

MAILING CERTIFICATE UNDER 37 C.F.R. § 1.8(A)

I hereby certify that the above correspondence is being deposited with the U.S. Postal Service as first Class Mail in an envelope addressed to Commissioner for Patents, Alexandria, VA 22313-1450.

Marianna Smith

Dear Sir:

P.O. Box 1450

Commissioner for Patents

Alexandria, VA 22313-1450

With respect to the Restriction Requirement mailed on 8/24/2004, the Examiner has restricted the instant application to the invention of Group I (Claims 1-14 and 18-20) or Group II (Claims 15-17). In light of this, Applicant elects Group I, (Claims 1-14 and 18-20) with traverse.

The Examiner asserts that "the product as claimed can be made by another and materially different process such as forming a single mold layer with two holes and depositing two different metals in it." Applicant submits that the materially different process proposed by the Examiner falls within the scope of claims 1-14 and 18-20 and is thus not a materially different process.

Applicant elects species I with traverse. The species restriction is unclear as both species I and species Iii are defined as the embodiment described in paragraph 21. Claims 1-14 read on species I.

Respectfully submitted,

Attorney for Applicant Reg. No. 36,144

Texas Instruments Incorporated P.O. Box 655474, M/S 3999 Dallas, TX 75265 (214) 532-9348 or (972) 917-5643 Fax: (972) 917-4418